

Information Disclosure Citation Listing

Form PTO-1449 U.S. Department of Commerce (Rev. 7-80) Patent and Trademark Office 42-44F (F-49) INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)		Atty. Docket No.: F-9089		Serial No.: 10/578,047			
		Applicant: Joachim MAI, et al.					
		Filing Date:		Group:			
U.S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
		US-					
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation Yes No
	F1	DE- 4108404	10/10/1991	DE			N*
	F2	DE- 39724	1/23/1964	DE			N ^P
TRANSLATION KEY: * English Abstract. ^F Concise statement of relevance provided in foreign search report. ^C Concise statement of relevance provided in specification or in attachment to document. ^S Concise statement of relevance provided in IDS. ^P Relevant portion of document translated. ^O English abstract only - copy of document in pct search.							
OTHER INFORMATION DISCLOSURE CITATIONS (Including Author, Title, Date, Pertinent Pages, Etc.)							
	01	5/21/2003 "Reactive etching of semiconductor surfaces using an electronically chopped low energy broad beam ion source" J. Dienelt et al. Elsevier Science B.V., Surface and Coatings Technology Volumes 174-175 Pages 157-161					
	02	7/17/2003 "Generation of a pulsed ion beam with a tuned electronic beam switch" J. Dienelt et al. Plasma Sources Science and Technology Vol. 12 Pages 489-494					
EXAMINER				DATE CONSIDERED			
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							